

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Hiroshi KOYAMA et al.

Application No.: 10/528,111

Confirmation No.: 9042

Filed: March 16, 2005

Art Unit: 1713

For: FLUORINE-ATOM-CONTAINING
POLYMERIZABLE UNSATURATED-
MONOMER, FLUORINE-ATOM-
CONTAINING POLYMERIC COMPOUND
AND PHOTORESIST RESIN COMPOSITION

Examiner: H. S. Hu

REPLY TO UNITY OF INVENTION REJECTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the Unity of Invention Rejection dated April 23, 2007, the following remarks are respectfully submitted in connection with the above-identified application.

This reply includes: Remarks.